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	APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
	10/501,733	02/11/2005	Robert Crombach	4662-330	4375	
	23117 7	7590 . 11/15/2006		EXAM	EXAMINER	
90	NIXON & VANDERHYE, PC 901 NORTH GLEBE ROAD, 11TH FLOOR			LISTVOYB, GREGORY		
	ARLINGTON.	•	LOOK	ART UNIT	PAPER NUMBER	
				1711		
				DATE MAILED: 11/15/2006		

Please find below and/or attached an Office communication concerning this application or proceeding.

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1		Application No.	Applicant(s)	<i>V</i>				
		10/501,733	CROMBACH ET AL.					
	Office Action Summary	Examiner	Art Unit					
		Gregory Listvoyb	1711					
Period fo	The MAILING DATE of this communication app or Reply	ears on the cover sheet with the c	correspondence address -	-				
A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 3 MONTH(S) OR THIRTY (30) DAYS, WHICHEVER IS LONGER, FROM THE MAILING DATE OF THIS COMMUNICATION. - Extensions of time may be available under the provisions of 37 CFR 1.136(a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication. - If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication. - Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133). Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b).								
Status								
1) ☐ 2a) ☐ 3) ☐	Responsive to communication(s) filed on This action is FINAL. 2b) This Since this application is in condition for allowar closed in accordance with the practice under E	action is non-final. nce except for formal matters, pro		s is				
Disposit	ion of Claims							
4)⊠ 5)□ 6)⊠ 7)□	Claim(s) <u>1-13</u> is/are pending in the application. 4a) Of the above claim(s) is/are withdray Claim(s) is/are allowed. Claim(s) <u>1-13</u> is/are rejected. Claim(s) is/are objected to. Claim(s) are subject to restriction and/o	wn from consideration.						
Applicat	ion Papers							
10)	The specification is objected to by the Examiner. The drawing(s) filed on is/are: a) accepted or b) objected to by the Examiner. Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a). Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d). The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152.							
Priority :	under 35 U.S.C. § 119							
 12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f). a) All b) Some * c) None of: 1. Certified copies of the priority documents have been received. 2. Certified copies of the priority documents have been received in Application No. 3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)). * See the attached detailed Office action for a list of the certified copies not received. 								
2) Notice 3) Information	nt(s) ce of References Cited (PTO-892) ce of Draftsperson's Patent Drawing Review (PTO-948) rmation Disclosure Statement(s) (PTO/SB/08) er No(s)/Mail Date	4) Interview Summary Paper No(s)/Mail D 5) Notice of Informal I 6) Other:	oate					

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DETAILED ACTION

Claim Rejections - 35 USC § 102

The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

(b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States

Claims 1, 3-12 rejected under 35 U.S.C. 102(b) as being anticipated by Berger et al (WO 9724389 and US Patent 5859177), herein Berger.

Berger discloses a process for postcondensation of polycondensates, especially polyamide 6.6 granulate, in a fluidized bed reactor using nitrogen as the carrier gas.

On the first stage of the process Nitrogen gas is saturated with water at dew point about 80. The reaction temperature is within the range of 50-195 C (Figure 2). At the second stage of the process the dew point of Nitrogen stream decreases from 80C to 20C. At the same time, the reaction temperature decreases to 58C.

Typical melting point of polyamide 6,6 is within the range of 250C-260C. Therefore, the limitations of Claims 3 and 8 are met.

Viscosity values of Polyamide 6,6 are between 75.6 and 91.5. Therefore, the limitations of Claims 10 and 12 are met (Column 4, Table).

Viscosity numbers may increase with lower dew point of Nitrogen (Table, tests 2 and 4), meeting the limitations of Claim 11.

Claims 1-3, 8 and 13 rejected under 35 U.S.C. 102(b) as being anticipated by Dujari et al (WO 9823666 and US Patent 5955569), herein Dujari.

Dujari discloses a method for a solid state polymerization of polyamides. He teaches that the use of an ultra dry gas characterized by a dew point below 30C in combination with a phosphorus containing SPP catalyst leads to a markedly increased solid state polymerization rates at significantly lower reaction temperatures.

Dujari does not explicitly change the wetness of Nitrogen carrier gas. However, he teaches that the low dew point gas provides a driving force for diffusion of moisture from the interior to the surface of the polyamide pellets and evaporation of that water from the surface (column 3, line 1). Evaporation of water from the granules inevitably increases a wetness of a Nitrogen gas at the first stage of the process.

Dujary uses the pellets of low molecular weight poly(hexamethylene adipamide), nylon 6,6, polycaprolactam, nylon 6 with antioxidant present (Figure 1, Column 4, line 10).

Claims 1-2, 8 and 13 rejected under 35 U.S.C. 102(b) as being anticipated by Van Ruiten et al (WO 03006724, US patent 6911257), herein Van Ruiten.

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Van Ruiten discloses a process for the manufacture of homopolyamide –4,6 fibers. He teaches the solid-state post condensation (SSPC) is performed in water containing gas atmosphere having a dew temperature at atmospheric pressure between 5C and 100C. At dew temperature above 5C less discoloration occurs. The dew temperature may be chosen such that the yellowness index is lower than 20. After SSPC in the presence of water vapor, drying at dry conditions may be performed to reduce the water content of the polyamide-4,6 (column 5, line 25). Therefore, at the second stage of the process (drying) the surrounding inert gas should be substantially dry.

Claims 1-2, 8 and 13 rejected under 35 U.S.C. 102(b) as being anticipated by Beaton (US patent 3821171), herein Beaton.

Beaton teaches a continuous, solid-phase polymerization process for increasing the molecular weight of polyamide granules with an inert gas at an elevated temperature. Preferably, the inert gas is substantially free of moisture (Column 4, line 35). He suggests that it is cheaper to recirculate gas, but it's lead to a higher moisture content, decreasing the rate of the reaction (Column 4, line 40). Therefore, actual wetness of the inert gas increases at the first stage of the process and then decreases with reaction completion.

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Any inquiry concerning this communication or earlier communications from the examiner should be directed to Gregory Listvoyb whose telephone number is (571) 272-6105. The examiner can normally be reached on 9am-6pm.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, James Seidleck can be reached on (571) 272-1078. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free). If you would like assistance from a USPTO Customer Service Representative or access to the automated information system, call 800-786-9199 (IN USA OR CANADA) or 571-272-1000.

> Gregory Listvoyb Examiner

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James J. Seidleok Supervisory Patent Examiner Technology Center 1700